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Gamma Radiation as a Function of Distance Project 13.3a.

October 1955

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Nevada Test Site

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FOREWORD

This report has had classified material removed in order to make the information available on an unclassified, open publication basis, to any interested parties. This effort to declassify this report has been accomplished specifically to support the Department of Defense Nuclear Test Personnel Review (NTPR) Program. The objective is to facilitate studies of the low levels of radiation received by some individuals during the atmospheric nuclear test program by making as much information as possible available to all interested parties.

The material which has been deleted is all currently classified as Restricted Data or Formerly Restricted Data under the provision of the Atomic Energy Act of 1954, (as amended) or is National Security Information.

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It is the belief of the individuals who have participated in preparing this report by deleting the classified material and of the Defense Nuclear Agency that the report accurately portrays the contents of the original and that the deleted material is of little or no significance to studies into the amounts or types of radiation received by any individuals during the atmospheric nuclear test program.

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ABSTRACT

Garma radiation exposure measurements were made as a function of distance on the Bee, Apple I, Wasp Prime, Apple II, and Zucchini shots of Operation Teapot. The Apple I, Wasp Prime, and Zucchini gamma measurements scaled with yield, the Bee results were high by about 50%, and the Apple II measurements were affected by the clouds passing over the instrument line. The measurements made with the LASL aluminum-wood and the NBS lead-tin-Bakelite film badges are compared with the energy-independent Victoreen thimble chamber readings. The approximate film values relative to thimble chamber values are the following: in the aluminum badge, film types 502 and 510 were 10% high, and types 606 and 1290 were 20% high; in the NBS badge, 502 was 7% low, 510 was 19% low, 606 was 10% low, and 1290 was essentially correct.

ACKNOWLEDGEMENTS

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1. Introduction

During Nevala operations prior to Teapot, both the Evans Signal Laboratory (ESL) and the Los Alamos Scientific Laboratory (LASL) measured gamma radiation as a function of distance on many of the shots, using film badges. The measurements of the two laboratories have not been in agreement, the LASL values being generally higher than the ESL values. In 1953 an intercalibration between LASL and the National Bureau of Standards (NBS) revealed an error of 13% in the LASL measurements, but the major portion of the discrepancy has remained unresolved.

Since the primary purpose of the LASL measurements was to determine whether the gamma radiation from the various devices tested on these operations scaled with yield, which is a relative determination, no correction for this calibration error was made nor were further attempts made at finding additional errors. However, prior to the Teapot operation it became apparent that there was a need for a clarification of the results, including a determination of absolute exposure values. The widely differing response of the ESL and LASL badges to low energy gamma radiation appeared to be a likely source of error in both ESL and LASL measurements. It was therefore decided to compare film badge measurements with those obtained with Victoreen thimble chambers, which are essentially independent of energy above 30 kev.

2. Methods and Procedures

2.1 Film Types

The film types employed on previous tests by the two groups and their approximate exposure ranges are as follows:

Exposu	re range, r	LASL fil	m type	ESL film	type
0.1	- 10	Du Pont	502	Du Pont	508
1	- 20	Du Pont	510	Du Pont	510
15	- 200	Du Pont	606	Du Pont	606
20	- 1000	Du Pont	1290 (Adlux)	Du Pont	1290 (Adlux)
1000	- 10,000	Eastman	548-0	Eastman	548-0

It should be noted that the film types are identical with the exception of the lowest exposure range, where LASL used type 502 and ESL used type 508. Of the six film types listed above, only Du Pont 502, 510, 606, and 1290 were used on Operation Teapot. An attempt was made by LASL to obtain some Du Pont 508 film from the ESL group in Nevada during the operation, but ESL had discontinued using this film type after Operation Upshot-Knothole and was using Du Pont 502. The high-range Eastman 548-0 had been used only to a limited extent by LASL on previous tests and consequently was not included in the Teapot measurements.

2.2 Film Badges

The film badge used by LASL consists of a slotted wooden cylinder 2-5/8 in. in diameter and 6 in. in length enclosed in a 1/16 in. thick aluminum can mounted on an angle-iron stake. This badge will be referred to as the aluminum-wood or AW badge.

The film badge used by ESL consists of a Bakelite container having an 8.25 mm wall thickness covered with layers of 1.07 mm of tin and 0.3 mm of lead. A 0.78 mm thick lead strip is wrapped around the outer edge of the badge and the entire assembly is placed in a plastic cigarette case and mounted on a metal stake. This badge, designed by Ehrlich of the National Bureau of Standards, is usually referred to as the NBS badge.

Three other badges were used to some extent on Teapot. One of these, which will be called the B-C badge, consisted of two separate filters, each filter containing varying amounts of six elements. Although this badge is still in the design stage, the decision was made to use it because of its somewhat unique response in the very low energy region.

At the request of Joe Deal of the AEC, a film badge constructed by Edgerton, Germeshausen, and Grier (EG&G), and a film badge used by the British on their test operations were also used. The EG&G badge is similar in design to the NBS badge except that the Bakelite container has been replaced with a polyethylene container. The British badge consists of a 1.0 mm tin filter and a thin plastic jacket; Ilford film type PM 3 was used with this badge.

The five film badges used on Teapot are shown in Fig. 1.

2.3 Film Calibration

The films used by LASL in the AW badge have been calibrated in the past with radiation from a 22 Mev betatron. In 1953, an intercalibration was performed in which film types 1290 and 606 were exposed in the NBS and AW badges to radiation from NBS and LASL betatrons operating at peak energies of 10 and 22 Mev, respectively. To eliminate possible inconsistencies in developing, two sets of exposures were made and each labcratory processed a complete set of 10 and 22 Mev film calibrations with essentially identical results. The results, reported in NBS Report 8A-121, showed that the films in the NBS and AW badge have the same response to 10 Mev radiation. The film response of the NBS badge at 22 Mev was somewhat high, but this effect does not influence the field discrepancy since ESL did not calibrate at this high energy. The film response in the AW badge was found to be 13% lower at 22 Mev than at 10 Mev, and subsequent measurements at LASL demonstrated that the thickness of aluminum and wood in the badge was not sufficient to provide ionic equilibrium at the higher energies. This 13% lower response at the 22 Mev calibration energy means that the interpreted field measurements were high by this amount, because distances from the source were great enough to provide ionic equilibrium.

Two different radium sources were used for calibrating the film badges for Operation Teapot, one approximately 0.2 curies and the other approximately 2.3 curies. The rhm (roentgens per hour at 1 meter) of the 0.2 curie source had been measured by NBS to within +1%. The 2.3 curie

source was calibrated by comparing the current it produced in a Victoreen thimble chamber attached to a vibrating-reed electrometer to the current produced under identical conditions by the known 0.2 curie source. After the operation, both sources were again measured using Victoreen thimble chambers which had just been calibrated by Frank Day of NBS to energies ranging from 0.05 to 1.3 Mev and found to be independent of energy within +5%. The source output of the two radium sources as measured with the thimble chambers agreed to within +3% of the previous calibrations. Typical calibration curves for Du Pont 502, 510, 606, and 1290 are shown in Fig. 2. Although only the points obtained with the films in the NBS and AW badges are shown, the curves were constructed with the data from the NBS, AW, B-C, and EG&G badges. There is a small but consistent trend for the NBS badge points to lie below those of the AW badge, but the presumably similar EG&G badge gave points which tended to be slightly higher than the NBS points. However, 90% of the points for all badges were, in terms of exposure, within 5% of the composite curves shown.

2.4 Energy Dependence of the Film Badges

The energy dependence of the various film types used on these tests in the AW and NBS badges is shown in Fig. 3. The AW badge 606 and 1290 curves and all four NBS badge curves are based on measurements made by Ehrlich. The AW badge 502 and 510 curves were constructed using unfiltered film measurements made by Ehrlich and the true absorption coefficients given by White in NBS Report 1003. As may be seen, the AW badge

has a large overresponse for energies below 250 kev and the NBS badge has a large underresponse below 100 kev. If the spectrum of the measured gamma radiation contains components in the low energy region, resulting from the source spectrum or from multiple scattering in air, the AW badge would overevaluate and the NBS badge would underevaluate the exposure. This possible difference is in the direction of the generally observed discrepancy on previous operations.

The calculated response of filter B in the B-C badge to monochromatic radiation is shown in Fig. 3. Between 50 and 90 kev the area under this curve is equal to the area under a curve of unit sensitivity. The response for filter C is only slightly different from B, because of small differences in the relative amounts of the same elements. The discontinuities in the curve occur at the K-edges of the six elements making up the filter. As indicated in Fig. 3, measurements made with 40 to 75 kev monochromatic radiation gave excellent agreement with the calculated response; however, about 90 kev hard-filtered x-rays gave a much higher response than calculated. It was this latter feature which resulted in the use of thimble chambers in the field, rather than the B-C badge, as standards with which to compare the AW and NBS badges. showed the B-C badge to have a Initial results from Bee greater response than the AW badge, indicating the need for air-equilibrium material between the filters and the film. Subsequent use of such material resulted in obtaining the same response with the B-C badge as with the AW badge. Incidentally, measurements made by Ehrlich

after the operation demonstrated that the overresponse of the B-C badge above 90 kev was due to fluorescent radiation from the elements in the filter.

2.5 Victoreen Thimble Chambers

Victoreen thimble chambers have long been used in the laboratory as secondary standards for measuring exposures. The response of these instruments, as determined by Day of NES, is essentially independent of energy above 30 kev. Both before and after the operation the chambers were calibrated to better than 5% accuracy with the 2.3 curie radium source. Tests for charge-leak were made in the laboratory and in the field over periods of 1 to 15 days. Table 1 lists the calibration and charge-leak correction factors for each chamber. Table 2 gives air densities, pressures, and temperatures and the applied pressure-temperature correction factors for the five tests on which measurements were made. Only six chambers, varying in full scale sensitivity from 2.5 to 250 r, were available for the Bee, Apple I, and Wasp Prime tests. Fifteen chambers were used on the Apple II shot and 13 on the Zucchini shot. For mechanical protection in the field, a cylindrical Lucite cap with a 1/16 in. wall and lined with aluminum foil, was placed over each chamber. This assembly was held approximately 10 in. above ground by a 2 in. square wood stake. The additional Lucite did not affect the response of the chambers, because it added an amount of air-like material which was insignificant compared with the amount of air already existing between

the source and the chambers. None of the chambers was damaged by the detonations, although two chambers located 2900 yd from ground zero on Apple II were accidently destroyed by an Army tank shortly before recovery.

3. Results

The exposures as a function of distance measured with chambers and film badges on the Bee, Apple I, Wasp Prime, Apple II, and Zucchini shots are given in Table 3. The calculated rd² (exposure times distance squared) values are given in Table 4 as a function of distance. The rd² vs d curves for the chambers, the AW badge, and the NBS badge are shown in Figs. 4, 5, and 6, respectively; also shown are the curves normalized to an air density of 1.055 g/l.

Table 5 gives the rd² values obtained from the normalized curves for each instrument at 3000 yd. The ratios of these rd² values measured on the Bee, Apple I, Wasp Prime, and Apple II tests to the rd² value measured on the Zucchini test are also given in the table, together with the yields obtained from these ratios by assuming a yield of 28 kt for

Zucchini The radiochemistry yields are given in the same table for purposes of comparison.

The following sets of exposure ratios are given in Table 6 for each film type, test, and each distance at which measurements were made: AW badge to chamber, NBS badge to chamber, and AW badge to NBS badge.

Results obtained with the B-C, British, and EG&G badges are given in Table 3.

4. Discussion of Results

4.1 Yield

The yield calculations in Table 5 show that the garma radiation exposure on the Apple I, Wasp Prime, and Zucchini tests varied proportionately with yield, and that the chambers, AW badges, and NBS badges scaled equally well. Since there is no reason connected with the Apple II device itself that should prevent scaling, the apparent increase of exposure per kiloton is probably due to the fission cloud, which was observed to pass over the instrument line. The resultant ground pattern of the contamination strengthens this conclusion. Once before, on the

4.2 Comparison of Chambers and Film Badges

The various ratios for each instrument appearing in Table 6 were averaged for all distances and the results are given in Table 7. Thus there are averages of AW to chamber, NBS to chamber, and AW to NBS for each film type and for each test. Shown in Table 8 are the ratios for

the various film, film badge, and chamber combinations averaged over all distances and tests, these being called pooled averages. No pooled averages with Apple II measurements are given because of the previously mentioned inconsistency due to the fission cloud; had these data been included the AW to chamber and the NBS to chamber ratios would have been somewhat lower. Although there is considerable scatter in the data, there appear to be trends from which certain conclusions may be drawn.

With the exception of the Apple II measurements, the AW badge gave consistently higher values than the chambers. The 502 and 510 films were about 10% higher, and the 606 and 1290 about 20% higher than the chambers. In the NBS badge the 502 films averaged about 7% lower than the chambers, the 510 about 19% lower, the 606 about 10% lower, and the 1290 essentially the same as the chambers.

Because of a lack of thimble chambers there were more AW/NBS values than ratios involving thimble chambers.

In every case, the exposures measured in the AW badge were higher than those measured in the NBS badge, the average difference varying with film types as follows: the 502 film, 16% higher; 510, 36%; 606, 34%; and 1290, 21%. The Apple II data are not included in the weighted averages used to obtain these differences.

The few measurements made with the three other badges indicate that the B-C and British badges gave essentially the same results as the AW hadge, and the EG&G badge gave about the same results as the NBS badge.

4.3 Interpretation in Terms of Energy Dependence

Figure 3 shows that between 40 and 100 kev the AW badge is much more sensitive than the NBS badge, more than 100 to 1 at 40 kev. Since the largest difference found between the two badges was 36%, the spectrum seen by the badge contains very little energy in this range. This same conclusion is obtained by considering that the B-C and AW badges gave the same measured values even though the AW badge is as much as 20 times more sensitive than the B-C badge in the 40 to 100 kev region.

In the 100 to 250 kev range the AW and B-C badges have an overresponse. A significant amount of energy in this region might account
for the 10 to 20% greater response relative to the thimble chambers
which these badges exhibited. If significant energy components exist in
this range, the NBS badge would give lower exposures than the AW and B-C
badges, a result actually obtained. However, the ratios obtained with
the various film types in the NBS badge are not consistent with their
energy dependence curves. From these curves one would have expected the
510 film to read higher than the 606 film, and the 606 film to read
higher than the 502 and 1290 films, but precisely the opposite trend was
found. Thus, if the differences found between the various film types in
the NBS badge are due to radiation from 100 to 250 kev, the energy
dependence curves must be invalid in this energy range.

There are small differences in film response to 10 Mev betatron radiation but these are not the correct magnitude nor direction to account for the differences obtained.

Thus, it appears as though nearly all the gamma radiation had an energy greater than 250 kev, and the presence of only extremely small amounts of radiation between 40 and 250 kev would be sufficient to give the small differences found.

4.4 The LASL and ESL Discrepancy on Previous Tests

4.4.1 LASL Measurements

As mentioned in Section 2.3, there has been in the past a 13% error in LASL gamma radiation vs distance measurements due to calibration.

Assuming the thimble chambers measured the exposure correctly on the Teapot operation, there has been an additional error in the LASL measurements, probably due to energy dependence, which amounts to 10% with the 502 and 510 films and 20% with the 606 and 1290 films. Thus, in comparing the Teapot thimble chamber measurements to the AW badge film measurements made on previous tests, one should expect the film measurements to be high at the near distances by about 33% and high at the far distances by 23%. The Ranger F film measurements have been used as a "standard" to which subsequent measurements have been scaled; Fig. 7 shows the Ranger F and the Zucchini rd² vs d curves normalized to an air density of 1.055 g/l. At 2000 yards the Ranger F curve is 30% higher than the Zucchini curve and at 3000 yards it is 22% higher.

4.4.2 ESL Measurements

Assuming the thimble chambers measured the exposure correctly, there has been an error in the ESL measurements, presumably due to energy

dependence, which amounts to 10% with the 606 film, 19% with the 510, 7% with the 502, and no error with the 1290. No measurements were made with the 508 film.

The correction factors given above were applied to a few tests on which both ESL and LASL had made measurements. Although the exposure values were in much better agreement after correction, inconsistent discrepancies were still apparent. For example, on the Tumbler 2

test the corrected LASL measurements remained higher than the corrected ESL measurements; on the Upshot 5 test the measurements were in agreement, and on the Snapper 2 test the ESL measurements were higher than the LASL measurements. The largest discrepancies occur in the ranges in which ESL used Du Pont 508.

ESL's preliminary Teapot report, ITR-1115, does not include Apple
II and Zucchini results, but there are a few distances on the Bee, Apple
I, and Wasp Prime tests where measurements can be compared. Table 9
shows the exposure values obtained by ESL in the NBS badge, film type
unspecified, and the LASL measurements in the NBS badge. The reasonable
agreement lends encouragement to the idea that with further measurements
on the next Nevada operation, it should be possible to determine accurately the manner in which exposure vs distance varies with yield. Correction factors can then be applied to data collected on previous tests.

TABLE 1 THIMBLE CHAMBER CORRECTION FACTORS FOR SENSITIVITY

AND CHARGE LEAKAGE

Chamber	Sensitivity correction factor*	Charge leakage correction factor per 24 hr
2.5 r #1	1.09	< 1.01
10 r #1	1.30	< 1.01
10 r #2	1.07	< 1.01
25 r #1	1.17	< 1.01
25 r #2	1.09	< 1.01
25 r #3	1.12	<1.01
25 r #4	1.17	<1.01
25 r #5	1.20	<1.01
25 r #6	1.18	<1.01
100 r #3	1.02	<1.01
100 r #4	1.04	1.02
100 r #5	1.07	1.015
100 r #6	1.04	1.05
100 r #7	1.08	1.01
250 r #1	0.82	1.07
250 r #2	0.87	1.05

^{*}Preponderance of correction factors greater than 1 could arise from using an electrometer with a lower sensitivity than the chambers were designed for. This possibility was not determined.

TABLE 2 AIR DENSITIES, PRESSURES, TEMPERATURES, AND PRESSURE-TEMPERATURE CORRECTION FACTORS APPLIED TO VICTOREEN THIMBLE CHAMBERS

	Air	Air densities, g/l	1/8	7	\$	Pressure-
Shot	Ground	Burst	Average	pressure	tenperature,	correction factor
Bee	1,162	1,088	1,125	667.2	566	1.027
Apple I	1.107	1.043	1,075	652.7	284	1.121
Wasp Prine	1.043	1.032	1,038	653.2	284	1,121
Apple II	1,100	1.035	1,068	653.8	276	1.086
Zucchini	1,104	1,081	1,092	656.3	276	1.084

TABLE 3 EXPOSURE VS DISTANCE FOR CHANBERS AND FILM BADGES

British badge ex- posures, r (PM 3)							
502 510 606 1290							
1290				54		8	
pesur 606				13		23	
#4ge ex		0.0		3.3		5,5	2.7
B-C badge exposures, r 502 510 606 1290		8.7 5.0 2.25 0.98		000		01.0	
1290	abot	28	Readings taken on Apple I shot	981	Readings taken on Wasp Prime shot	2382	
NBS badge exposures, r 502 510 606 1290	Readings taken on Bee shot	3 2	-ppl	%ä	5	8888	
adge exp	le le	6.2	8	12. 1.6 1.2 1.5	es no	3.5 6.0	E 0
bed S		255.2	take	7.0 7.0 7.0 7.0 7.0 7.0 7.0 7.0 7.0 7.0	- Files	71°	5.7. 5.7. 5.7. 5.7. 5.7.
NBS b		7.3 1.55 0.72	egupp.	ผู้พูงคู่อ	176	6-2	1000
1290		3 8	Ne.	23 23	Read	25 110 120 120 120 120 120 120 120 120 120	
904:LF8	1	26.23		33 6		12 25	
dge exp 510		8.3 L.2		44. 1. 1. 1. 1. 1. 1. 1. 1. 1. 1. 1. 1. 1.		23 2.4	12.4
AW bedge exposures, r cro <10 606 1290	1	8 1 2 0 0 0 0 0 0 0 0 0 0 0 0 0 0 0 0 0 0		8 2 4 4 6 6		or	
Thimble chambers Exposure,		51.2 25.0 25.0 8.51 1.75 0.661		10.8 10.8 5.52 5.75 0.75		33.5 17.4	1.98
	1	. 222424		200484		22.23	25 r M
1144	10000	250 100 25 100 25 101 27 101 27 101		250 1 20 1 20 1 20 1 20 1 20 1 20 1 20 1		883	\$2
Distance,	P.	250 250 250 250 250 250 250 250 250 250		2200 2200 2500 2500 2500 2500 2500 2500		1250 1150 1650 1850 2010	22FC 25FC 25FC 25FC 25FC

TABLE 3 EXPOSURE VS DISTANCE FOR CHANGERS AND FILM BADGES (continued)

British badge ex-	(FM 3)				10.5 6.5 5.b	3.3			
EG&G badge exposures, r	1290		000	3322					
arpoor			525	3372					
a de	\$05 510 606			8	22				
90	3								
, ,	1290		250	18					
8-C badge exposures, r	909 019		071	18					44.00
¥ 2	500 510	٠							3.00
MBS badge axposures, r	502 510 606 1290	Readings taken on Apple II shot	30 20 00 20 80 80 80 80 80 80 80 80 80 80 80 80 80	.2328			Readings taken on Zucchini shot	rees krak	
nboda	\$	d App	9100	ፎሪዳይኒ	-4.0 E-	10	a Zucc	ระหมะผ	7 P F C O
S P	230	aken		10	24.65.4	3.5	8	នភិព	2 4 E 6 6 6
288	g	dings t			5.5	2.1	dings to		90 4 6 6 6 6 6 6 6 6 6 6 6 6 6 6 6 6 6 6
r.	1290	2	888888	ಜ೯೫೩	8		2	8883855458	
poet	\$		85	32432		0.0		និនិនឧសន	4000-
M badge exposures, r	510 606				22.22 5.54 5.6	2.6			01 7.5 7.5 7.5 7.5 7.5 7.5 7.5 7.5 7.5 7.5
A be	8				6.5	2.5			,
5	-		222	1 88.8 5.5	25.0 25.0 25.0	5.8L 1.2L		59.6 17.6 12.1	* * * * * * * * * * * * * * * * * * *
Pilable chambers	Treper		888	8888 8888 8888 8888	****** 	10 T D 1 S 1 T D 1		8888888 5488 5488 5488	8888 8 2548 5
•	Distance		1500			888 888 888 888 888		2200 2200 2200 2200 2200 2200 2200 220	

TABLE 4 CALCULATED VALUES OF EXPOSURE TIMES DISTANCE SQUARED VS DISTANCE

	Thimble	AW h	adge (x	206)		NBS b	adge (x	106)	
Distance,	(x 100)	502	510	606	1290	502	510	606	1290
<u>yd</u>	(X 10-)			alues fo	r Bee shot				,
1700 2000 2300 2500 2800 3100	180 100 15 30 11, 6,4	43 28 16 7.9	5ę դդ	240 100	2h3 110	39 26 13 6.9	33	180 70	200 80
		Calcula	ted val	ues for	Apple I sh	ot			- 1 -
2000 2200 2100 2600 2800 3000 3300	81 62 37 25 52 8.2	58 40 27 17	120 63 38 26 15	180 110	180 110	52 34 22 14 8.9	58 14 28 18 14	11 ₁ 1 ₁ 1	140 77
		Calcul	ated val	lues for	Wasp Prim	e shot			
1250 1150 1650 1850 2010 2210 21110 2610 2810 3010	91 60 61 12	12 29 17 11 7.	79 48 27 16 11	230 120 75 50	110 230 130 15 50 15	38 24 11 9.8 5.9 3.7	53 33 19 7.0	310 170 95 55	340 180 100 59

TABLE & CALCULATED VALUES OF EXPOSURE TIMES DISTANCE SQUARED VS DISTANCE (continued)

	m . 13a) (m	1061		NBS t	x) egbac	106)	
Distance,	Thimble chamber		adge (x	606	1290	502	510	606	1290
yd	$(x 10^{6})$	502	510						
		Calculate	d values	for App	ole II shot	t			
1500 1600 1700 1800 1900 2000 2100 2200 2300 2400 2500 2600 2700 2800 2900 3000 3400	650 550 460 490 300 170 130 110 96 86	73 55 46 26 17	119 98 88 68 56 45 27	580 140 340 260 220 130 120	2300 1100 1100 810 610 110 350 270 220 110 120	57 46 36 22 14	100 81 71, 61 49 40 32	580 400 330 230 180 130	1900 1100 920 650 190 280 220 180 120
3400		_	روامس المرا	os for 7	ucchini sh	not			
		Calcula	ted Valu	162 TOL 2					1200
1500 1600 1700 1800 1900 2000 2100 2200 2300 2400 2500 2600 2700 2800 2900 3000 3100	240 200 150 100 76 64 11 100 28 25	65 51 12 31 27 17	110 88 68 54 44 34 27 17	490 380 290 220 170 130 120	1400 1000 720 520 380 290 220 180 130 120	56 46 37 29 23 15	110 78 69 54 14 34 26 21	120 280 220 170 130 110	900 660 190 320 210 180 110

TABLE 5 COMPARISON OF YIELDS

Shot	rd ² (x 10 ⁶) at 3000 yd	Ratio Calculated	Yield, kt from thim	Radiochem, yield, kt ble chambers
Bee	13.0	0.42	11.8	8.1
Apple I	17.0	0.55	15.4	15.5
Wasp Prime	3.6	0.116	3.3	3.2
Apple II	48.0	1.55	43.3	30
Zucchini	31.0	1.00	28	28
		Calcul	ated from	AM badges
Bee	14.0	0.42	11.8	8.1
Apple I	18.5	0.55	15.1	15.5
Wasp Prime	4.1	0.122	3.1	3.2
Apple II	48.0	1.43	40.0	30
Zucchini	33.5	1.00	28	28
		Calcu	lated from	NBS badges
Bee	11.5	0.13	12.0	8.1
Apple I	15.0	0.56	15.7	15.5
Wasp Prime	3.1	0.115	3.2	3.2
Apple II	37.5	1.39	38.8	30
Zucchini	27.0	1.00	28	28

TABLE 6 EXPOSURE RATIOS FOR THIMBLE CHAMBER, AW BADGES, AND NBS BADGES

ber	12%		1.14		9.95		0.98	
NBS badge/thimble chamber	8		1.04 0.72	,	0.83		1.0L	
dge/thda	510	•	0.73		0.71 0.70 0.75 0.73 0.26		0.89	0° 91
NBS ba	205		0.86 0.92 1.09		0.83 0.90 0.28 1.08		0.63	1.26
mber	12%	£	1.37	shot	1.37	shot	1.26	
AW badge/thimble chamber	88	Bee sho	70° T	pple I	1.37	sp Prime	1.37	
adge/thi	510	tios for	0.98 0.86	os for !	111110 1000% 1000%	o for Wa	1.32	1.36
AW b	205	Exposure ratios for Bee shot	0.88 1.14 1.24	Exposure ratios for Apple I shot	0.92 1.07 1.08 0.33	Exposure ratios for Wasp Prime shot	99.0	1.46
	1290	Щ	1.20	ā	1.25 1.44	odzą	1.18	
AW badge/NBS badge	909		1.28		1.28		1.39	
badge/N	510		٦. پر		2.00 1.50 1.15 1.13 1.13		1,64	11.00 60.00 11.00
*	205		1.12		1.11 1.18 1.21 1.19		1.09	1.16
200	N.		1700 2300 2300 2300 3100		2000 2500 2500 2500 3000 3000		1250 1150 1650 1850 2060	2200 200 2600 2600 3000

TABLE 6 EXPOSURE RATIOS FOR THIMBLE CHAMBER, AW BADGES, AND NES BADGES (continued)

Ļ	12%			2.99	0.89	0.87		97.0	2.58	99.0								
chambe					0.72			****										
dable	8			ਤੰ	0	o	•	•	o	ŏ								
NES badge/thimble chamber	510								•	0.61	0.62	0.69	0.0	٠ ۲	•	8		
WBS b	8												;	99.0		9,0		0.97
ä	258			72.	21.1	8.	i	*75*	-72	3°0	ĸ							
chamb	Ä	shot																
table	8	le II			1.09	%		0.53	2.0	0.78	8							
AW badge/thimble chamber	510	for App									8	٠ <u>.</u>	٥. د	0.79		°.		
NY AV	8	Exposure ratios for Apple II shot										•	1	o. %	ij.	0.87		1.2
		rnsods																
•	12%	a	1.19	1.25	1.26	1.1	1.25	2.5	1.24	1.25								
AW badge/WBS badge	8				1.45	۲. ا	1.16	1.42	1.68	1.2		•						
/egpeq /	570										1.45	1.H	1.43	1.5	1.10	1.43		
*	8													1.27	1.18	1.28	1.19	1.25
	yd .		1500	38	8	8	8	8	8	8	8	8	8	S S	8	8	82	8
2	3		HH;	4 ñ	Ä	≈	~	ત્ <u>ર</u>	~	N	Ň	Ñ	N	Ñ	Ñ	ጝ	M	M

TABLE 6 EXPOSURE RATIOS FOR THIMBLE CHAMBER, AW BADGES, AND NBS BADGES (continued)

aber	1290				7	3.5	%								
NBS badge/thimble chamber	8				8	9.0	0.87								
adge/thi	510							0.77	5 6	1.00	0.87	0.8	0.82		
MBS b	8								9	86	0.92	ਰੌ	8.0		3°01
mber	250	¥			5	27.	1.19	1.14							
AW badge/thimble chamber	909	chini sh			,	21.1	1.12	1.14							
oadge/th	510	for Zuce						1.08	4,5	1.32	1.1	1.18	1,06		
7	ğ	Exposure ratios for Zucchini shot							,	1.25	1.8	1.18	1.08		3.40
	1290	Exposur	1.13	 96	1.17	1.21	1.23)							
AW badge/NBS badge	88			21.15	 %:	1.32	8,5								
/egbed w	510							1.41	1.27	2.5	1.27	1.29	1.3		
7	8								7	זין ר דין ר	1. 3.	7.1	1.15	ភូរ	1.13
2	yd yd		1500	1700 1800	1900	2700 2700	2200	250	2500	2002	, 60 78 78	2900	3000	3200	3700

* Not included in averages of Table 7.

TABLE 7 AVERAGE RATIOS, NUMBER OF MEASUREMENTS, AND STANDARD DEVIATIONS

	CO2 176	8	P13. \$10	\$10	F11m 606	905	Film 1290	1290
j	No. of values	Average and standard deviation	No. of values averaged	Average and standard devistion	No. of values	Average and standard deviation	No. of values averaged	Average and standard deviation
Solic Solic			Ratio of	AW badge to thimble chamber	mble chamber			
		. 80	•	0.92 + 0.06	2	21.0 + 61.1	2 د	1.24 ± 0.13
See	نہ دیـ	1.00 + 0.00	, - 3	01.0 = 61.1	e1 °	1.37	4 M	1.16 + 0.18
Apple 1 Wasp Prime	4 %	1.07 = 0.39	mv	0.87 + 0.03	w	0.89 + 0.06	~ 0	0.97 + 0.08
Apple II Zucchini	MW	1.11 + 0.04	·~	1.13 = 0.03	7	20°0 ₹ ŋ1°1	3	
	•		Ratio of	Ratio of NBS badge to thimble chamber	nimble chamb			•
		7	-	0.73	2	0.88 ± 0.16	۷ -	0.97 + 0.17
Bee Froje I	. 7 -7	0.92 + 0.06	.	0.72 + 0.02	ч «	0.83	1 W	1.04 + 0.06
Wasp Prime	0 m	0.94 + 0.31	20	0.62 + 0.02	1 VA M	0.68 + 0.07	νm	70.0 + 86.0
Apple 11 Zucchini	w	0.93 + 0.07	7	70°0 + 69°0	•	1		
			Ratio of	Ratio of AW badge to NBS badge	S badge			
9	1	1.1	H)	1.3 1.3	~ ~	1.1 3.16	0 O	86.
Apple I	won	1.18	ν= ν	1.10	ישחו	3,11,136	30°	1.23
Apple II Zucchini	^~	1:17	~	1.29	D			

TABLE 8 POOLED AVERAGES*

F11m 502	502	Film 510	510	F11m 606	909	FLF	F11m 1290
lo. of ralues everaged	Average and standard deviation	No. of values averaged	Average and standard deviation	No. of values averaged	Average and standard deviation	No. of values averaged	Average and standard deviation
	1.09 + 0.05	97	1.11 2 0.05	o	3.18 ± 0.05	10	1.20 ± 0.05
	0.93 ± 0.0h	15	0.81 ± 0.03	80	70.0 - 06.0	80	70.0 ₹ 66.0
	1.16	11	1.36	a	1.34	17	1.21

*Apple II not included.

TABLE 9 COMPARISON OF ESL AND LASL FILM MEASUREMENTS MADE WITH THE NBS BADGE ON TEAPOT

	Distance,	ESL results,	LASI 606	results,	510
Shot	yd	r			
Bee	1700	74.0	64	70	
	2000	18.0	18	20	
Apple I	2000	32	36	36	
Who I	2200	14	14	16	12
Wasp Prime	1250	200	200	550	
MESD LITTIE	1450	85	79	- 86	
	1650	34	35	37	
	1850	15	16	17	15.5



Fig. 1. Types of film badges used during Teapot: (1) aluminum-wood badge, (2) EGEG badge, (3) NBS badge, (4) British badge, and (5) B-C badge.

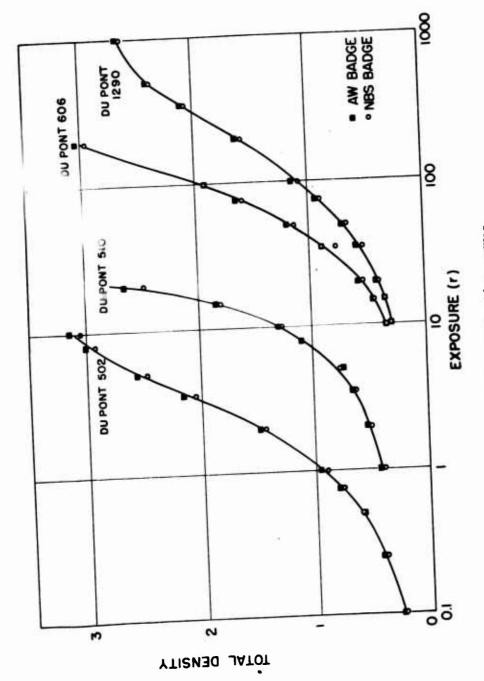


Fig. 2. Radium calibration curves.

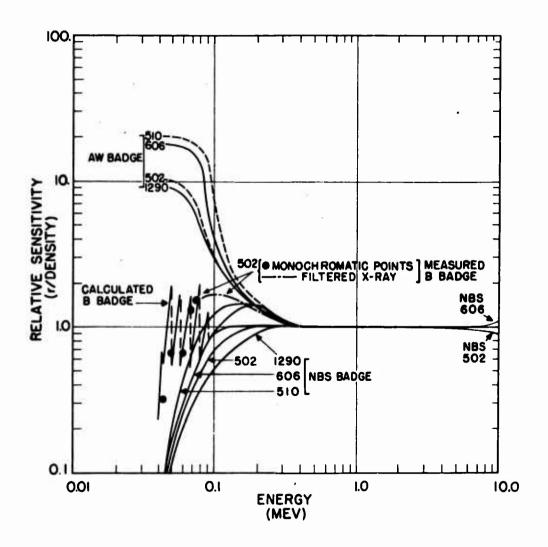


Fig. 3 Energy dependence of AW, NBS, and B section of .B-C badge.

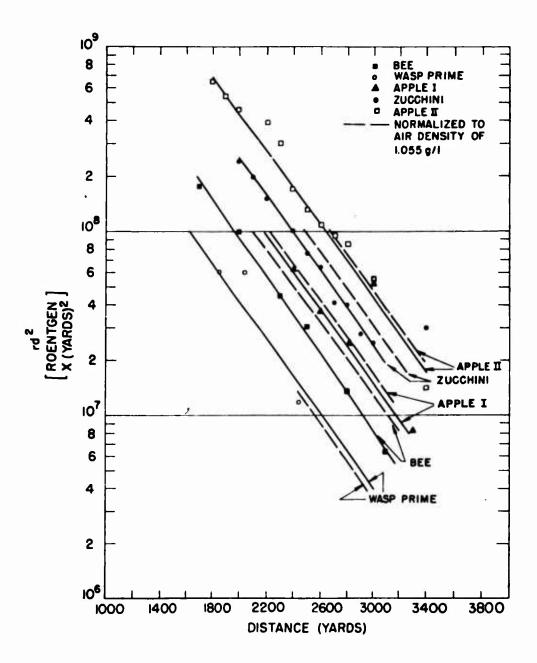


Fig. 4 Gamma radiation exposure times distance squared vs distance, measured with thimble chambers.

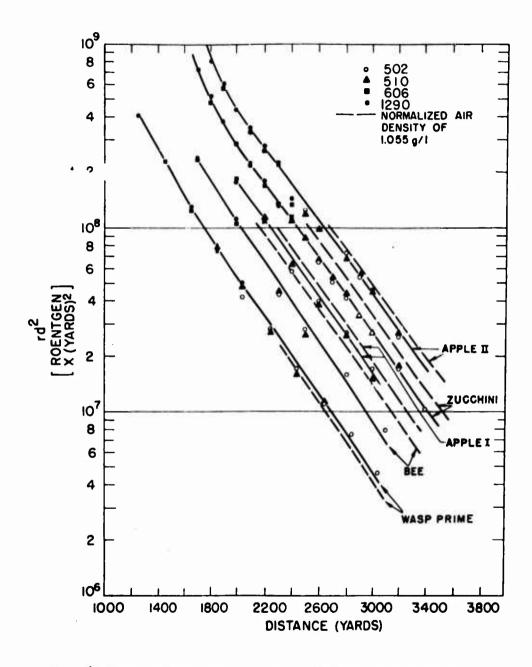


Fig. 5 Gamma radiation exposure times distance squared vs distance, measured with AW badges.

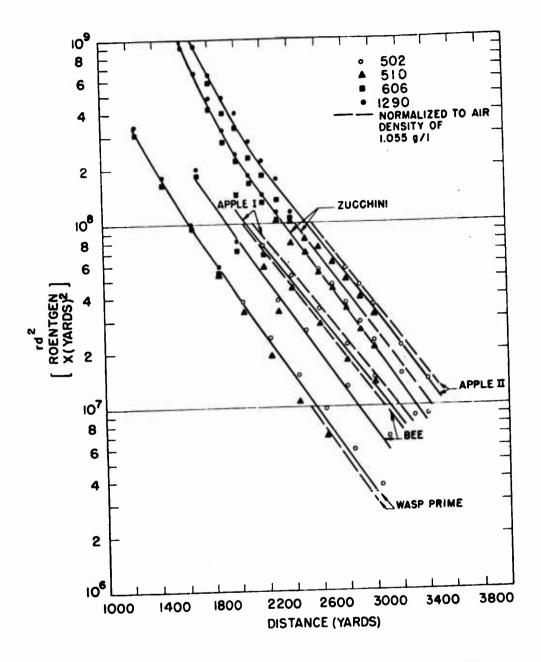


Fig. 6 Gamma radiation exposure times distance squared vs distance, measured with NBS badges.

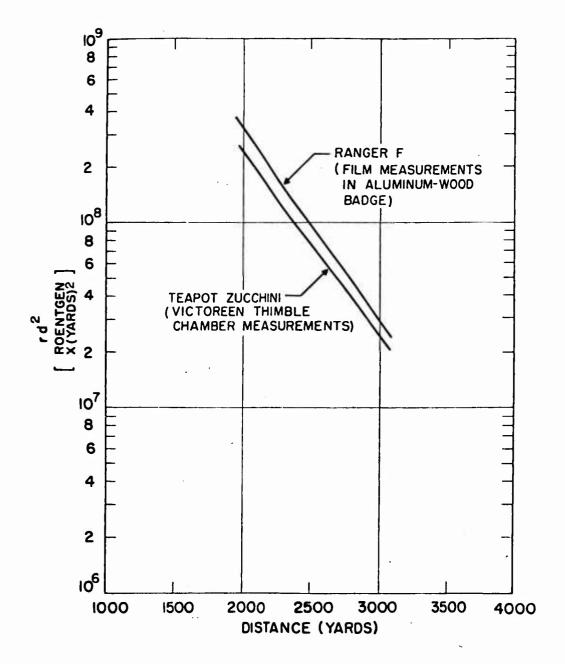


Fig. 7 Comparison of Teapot Zucchini and Ranger F rd² vs d curves normalized to an air density of 1.055 g/l and a yield of 22 kt.